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- 1. Introduction,**
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**Please use the following style for references:**

**[1] F. Auzel, O. L. Malta, J. Physique 44, 201 (1983).**

**[2] N. F. Mott, E. A. Davis, Electron Processes in Non-Crystalline Materials, Clarendon Press, Oxford (1979).**

**[3] A. M. Chinie, A. Stefan, S. Georgescu, O. Toma, E. Borca,**

**M. Bercu, presented at the 6-th International Balkan Workshop on Applied Physics, July 5-7 -th, 2005, Constanta, Romania (to be published in J. Optoelectron. Adv. Mater. 8(1) 2006.**